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1	Surface nanocrystallization of Cu and Ta by sliding friction
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14	Optimization of the surface structure and properties is of great concern in that the
15	failures of engineering materials such as wear, erosion and fatigue usually occur on
16	the surface of materials. Plastic deformation from the sliding friction process has been
17	utilized to realize surface nanocrystallization in commercial pure copper and tantalum
18	plates in this work. The optical microscopy, transmission electron microscopy, X-ray
19	photoelectron spectra, and uniaxial tensile testing results suggested that clean
20	nanocrystalline surface layers of pure copper and tantalum were obtained,
21	significantly strengthening the materials after the treatment.
22	Keywords: Nanostructured materials; Non-ferrous alloys; Grain refinement
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25 **1. Introduction**

A new family of severe plastic deformation processes have attracted considerable 26 27 scientific interests in order to generate nanocrystalline surface layer for bulk materials 28 [1]. Various surface deformation techniques have been developed by transforming the 29 initial coarse-grained (CG) structure of a bulk material into refined-grain structure, 30 such as surface mechanical attrition treatment (SMAT) [1], air blast shot peening [2], 31 wire-brushing [3], and surface mechanical grinding treatment (SMGT) [4]. These advances enhance several types of mechanical properties while keeping the overall 32 chemical composition of the target material unchanged. 33

Friction is a dissipative process encountered in daily life and industry 34 manufacture. Many experimental results have illustrated that microstructure in the 35 36 near-surface layer might be changed accordingly during friction and wear process 37 under different contact conditions. Surface microstructure observations showed that 38 plastic deformation could result in the formation of grains with a size falling into 39 nanometer regime. Grains in the surface layer of pure copper with a size less than 60 40 nm have been found in an early study on subsurface structure of pure copper abrased against SiC paper [5]. After sliding against the zirconia disc, the grain size in the 41 42 surface of the 316 stainless steel could be refined to 8-23 nm [6]. According to 43 Hughes's experimental results, the average geometrically necessary boundaries were only 10 nm, with nanocrystalline surface layer depth in excess of 4 μ m [7]. During 44 45 friction process, only one tenth of the energy was undertaken by wear, while most of 46 the energy was consumed in deformation, heat and noise et. al [8]. Thus it is supposed

that in case a suitable process is selected, wear loss can be controlled and more energy can be consumed in plastic deformation. A thick nanocrystalline surface layer in excess of 100 µm underneath the worn surface of pure copper induced by sliding against a WC-Co ball by utilizing a generic friction and wear tester has been reported elsewhere by the current authors [9]. These results further experimentally verified sliding friction as a potential approach to create nanocrystalline structures on the surface layer of metallic materials.

As such, we have developed a surface nanocrystallization technology by means of sliding friction treatment (SFT) with a specified device with enlarged sliding amplitude and improved controllable contact condition to scale up sample size. This work described the generation of nanostructured surface layer on pure copper and tantalum by sliding friction process and reported subsequent changes in the mechanical properties of the treated surfaces.

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61 **2. Experimental procedures**

99.95 wt% pure copper and tantalum plates with a size of $200 \times 200 \times 3 \text{ mm}^3$ and a roughness of 0.4 µm were annealed at 973 K and 1273 K, respectively, for 60 minutes, in order to eliminate the effect of mechanical processing on the surface and to homogenize the microstructure. The experiments were conducted on a special designed device in a ball-on-disc contact configuration as shown in Fig. 1(a), in which a spherical WC-Co ball of 10 mm in diameter bearing a normal load was static and the specimen (copper or tantalum) subjected to SFT was firmly installed in a table and

69	pressed together with the WC-Co ball under a preset normal force of 100-500 N. The
70	table moved independently along x and y axis driven by two motors. The sliding of
71	the specimen with an amplitude of 50 mm (d ₁) at a speed of 0.2 m/s (v ₁) with respect
72	to the WC-Co ball along x axis were made firstly, then table with the specimen shifted
73	along the y axis for a step of 100 μ m (d ₂), and the sliding process continued until the
74	area on the specimen surface is sliding treated. The sliding was carried out under
75	chlorcosane as lubricant for the tantalum while the copper was conducted under a dry
76	condition in an ambient environment. An image of a Cu sheet after SFT with a surface
77	roughness of 0.7 μ m and treated surface area of 100 mm ×150 mm is shown in Fig.
78	1(b).

The microstructure of the surface layer of the treated samples was characterized by using an Olympus PMG 3 optical microscopy (OM) and a JEOL JEM-2100 transmission electron microscope (TEM) operated at a voltage of 200 kV. Thin foil samples for TEM observations were cut from the treated surface layer and thinned by ion thinning at low temperatures.

X-ray photoelectron spectroscopy (XPS) was carried out on a Thermo Fisher ESCACAB 250XI spectrometer, by using monochromatic Al Ka radiation and detection pass energy ranging between 30 and 100 eV. Argon sputtering was applied at a pressure of 1×10^{-7} Pa under a 3 kV beam accelerating voltage.

The as-treated plates were mechanically polished on the top surface to remove 1-2 μ m in depth to eliminate the roughness effect on tensile properties. Down-sized tensile specimens shown in Fig. 1(c) were cut with the testing direction along the

99	3. Results and discussion
98	
97	loading.
96	extensometer was used to calibrate and measure the strain of the tested sample during
95	at a strain rate 5 \times 10 ⁻³ s ⁻¹ at room temperature. A contactless MTS LX300 Laser
94	System (MTS System Corporation, with a precision of force measurement of 10 mN)
93	designed thickness. Tensile tests were performed on a Tytron 250 Microforce Testing
92	polishing was performed from back side of the treated sample to a mirror finish with a
91	sliding direction by using electro-discharging machining. Afterwards, mechanical

3. Results and discussion 99

100 Figure 2 shows the microstructure from longitudinal cross-section of the Cu 101 sample before and after SFT. Plastic deformation and traces of plastic flow are 102 evident in the treated surface layer, instead of the original CG structure. After SFT at 100 N, the topmost deformed subsurface layer features discontinuous in a wave 103 104 pattern. This is similar to the vortex structure appeared in some local zones of the 105 upmost worn subsurface, which has been usually found [10-12] and checked in details by Yao [13] to be composed of severely refined grains. It is apparent that the plastic 106 107 flow lines extended to a greater depth as the load increases to 200 N, and the 108 deformed subsurface layer tends to be continuous, with grain boundaries bent towards 109 one direction with decreasing depth toward the surface.

110 As revealed by TEM morphologies and the corresponding selected area electron 111 diffraction (SAED) pattern in Figs. 2(d) and (e), elongated grains with random 112 crystallographic orientations are formed in the top surface layer of the sample. The

average transverse axis grain size (d_t) and longitudinal axis grain size (d_l) are 60 and 114 110 nm, respectively, although a certain number of grains approaching 200 nm are 115 also present. The grain size is slightly larger than that in the surface layer of the Cu 116 sample subjected to SMGT (22 nm, 45 nm in transverse axis and longitudinal axis 117 size respectively) under liquid nitrogen [4] and SMAT (10 nm) for 30 min [14].

118 Microstructures of the longitudinal cross-sectional Ta sample before and after 119 SFT are presented in Figs. 3(a)-(c). Initial Ta sample has an equiaxed grain structure with size of 30-60 µm (Fig. 3(a)), and after SFT at a load of 200 N, a plastic deformed 120 surface layer with the thickness exceeding 100 µm is formed clearly as shown in Fig. 121 122 3(b). When sliding load increases to 500 N, the deformation layer of about 300 μ m in depth is reached, as revealed in Fig. 3(c). Plastic flow lines are inclined to the surface 123 124 as they approached the worn surface, similar to the case for Cu in Fig. 2(c). The 125 detailed TEM observations show that roughly equiaxed grains with size ranging from 3 to 15 nm and an average grain size of 7 nm are formed in the topmost layer (Figs. 126 127 3(d) and (e)).

Materials in sliding contact develop large plastic strain and strain rate adjacent to the sliding interface in that actual contact took place in some asperities of the friction pair. Plastic shear strains in the range of 10–1000 have been reported [7, 15-17]. For example, based on the volume grain boundary area and von Mises relation, Hughes [17] extrapolated that the strain in the top-surface of copper subjected to friction was roughly 25 and the maximum shear strain rates being up to 5×10^3 s⁻¹. Owing to much high strain and high strain rate, a nanocrystalline structure will be produced, which

had been validated by large-scale molecular dynamics simulations [18] and considerable amounts of experiments over the past several decades [5-7, 19]. Current SFT has induced nanocrystalline structure on the subsurface for both Cu and Ta, and finer grain size for Ta than that for Cu may be attributed to the difficulty in dislocations recovery due to its higher melting temperature.

140 XPS results (Fig. 4) showed that C and O coming from the mating ball or 141 atmosphere were detected on the treated surface of the Cu and Ta samples, while the impurity contents decreased remarkably away from the surface. For example, after 142 etching 840 s, the C content was decreased by two orders of magnitude for the two 143 144 samples. The measured values from XPS are summarized in Table 1. It is reasonable to obtain clean nanocrystalline surface layer for Ta because the lubricant oil used 145 146 could alleviate wear and isolate the air from the contact surfaces. For the metals 147 sliding in air, it is common to produce oxides which are then available to 148 mechanically mix with unoxidized metal to form a mechanically mixed surface layer 149 [16, 20, 21]. In this work, large moving distance up to 50 mm imposed played a 150 dominant role in reducing impurity of the surface layer. Compared with our previous 151 study with a much lower travel distance (0.5 mm), the severe oxidation process and 152 subsequent behavior of oxide debris in between contact surfaces subjected to relative 153 slip will result in the thick oxide layer [22]. While in the present study during the 154 large distance sliding, the heat generated during friction should be radiated easily, 155 which can significantly alleviate oxidation. Moreover, it benefitted for the oxide 156 debris and contamination from transferred materials to be removed from the contact

zone. Consequently, a much thinner contamination layer was generated on thenanostructured surface layer of the treated sample.

159 Results from uniaxial tensile tests in Fig. 5 showed that the nanocrystalline 160 samples exhibited much higher yield strength (YS) and ultimate tensile strength (UTS) 161 compared with their CG counterparts for both Ta and Cu. The YS of the SFT Cu and 162 SFT Ta have reached 450 MPa and 720 MPa, respectively, which are considerably 163 higher than that of the corresponding CG samples (75 MPa for Cu and 300 MPa for Ta). However, the plasticity was depressed for the nanocrystalline samples, with an 164 elongation-to-failure less than 2% for both materials. It was reasonable that 165 166 nanocrystalline grains tended to significantly lose work hardening on deformation 167 owing to their very low dislocation storage efficiency inside tiny grains [23]. It was 168 noted that the SFT Cu with a 200 μ m in thickness exhibited a YS of 300 MPa and a 169 moderate elongation of 4.4. It was in well agreement with the results in [24] and 170 further verified that an approach using gradient nano-grained layers as advanced 171 coatings of bulk materials could enhance strength-ductility synergy of materials.

172

173 **4. Conclusions**

The sliding friction was used to refine the grain structure on the surface of pure Cu and Ta plates with a size scale up to 100 mm × 150 mm. The average grain size in the upmost surface layer of the Cu and Ta can be reduced down to 60 nm and 7 nm respectively. Surface contaminated layer from the ball-disc sliding is reasonably low in depth. The yield strength of the Cu and Ta has been improved from 75 MPa and

179	300 MPa to 450 MPa and 720 MPa after SFT, respectively. Current study revealed
180	that SFT was a promising process to realize nanocrystalline material surface with a
181	low contamination.
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- 217

218 Table 1. Variations of the element contents (in wt. %) with sputtering time from the

treated surface in the SFT samples. 219

220 — 221 — 222 — 223 — 224 — 225 — 226	Cu O C Ta O C	0 s 31 22 47 0 s 35.55 29.35 35.1	SFT Cu 60 s 91.2 1.89 6.91 SFT Ta 60 s 82.5 16.16 1.34	240 s 98.8 0.35 0.85 240 s 95.68 3.46 0.86	840 s 99.5 0.11 0.39 840 s 98.61 1.34 0.25
221 222 223 224 225 226	Cu O C Ta O C	0 s 31 22 47 0 s 35.55 29.35 35.1	60 s 91.2 1.89 6.91 SFT Ta 60 s 82.5 16.16 1.34	240 s 98.8 0.35 0.85 240 s 95.68 3.46 0.86	840 s 99.5 0.11 0.39 840 s 98.61 1.34 0.25
222 — 2222 — 2223 — 2224 — 2225 — 2226	Cu O C Ta O C	31 22 47 0 s 35.55 29.35 35.1	91.2 1.89 6.91 SFT Ta 60 s 82.5 16.16 1.34	98.8 0.35 0.85 240 s 95.68 3.46 0.86	99.5 0.11 0.39 840 s 98.61 1.34 0.25
222 223 224 225 226	O C Ta O C	22 47 0 s 35.55 29.35 35.1	1.89 6.91 SFT Ta 60 s 82.5 16.16 1.34	0.35 0.85 240 s 95.68 3.46 0.86	0.11 0.39 840 s 98.61 1.34 0.25
223 224 225 226	C Ta O C	47 0 s 35.55 29.35 35.1	6.91 SFT Ta 60 s 82.5 16.16 1.34	0.85 240 s 95.68 3.46 0.86	0.39 840 s 98.61 1.34 0.25
223 224 225 226	Ta O C	0 s 35.55 29.35 35.1	SFT Ta 60 s 82.5 16.16 1.34	240 s 95.68 3.46 0.86	840 s 98.61 1.34 0.25
224 — 225 — 226	Ta O C	0 s 35.55 29.35 35.1	60 s 82.5 16.16 1.34	240 s 95.68 3.46 0.86	840 s 98.61 1.34 0.25
224 225 226	Ta O C	35.55 29.35 35.1	82.5 16.16 1.34	95.68 3.46 0.86	98.61 1.34 0.25
225 <u> </u>	O C	29.35 35.1	16.16 1.34	3.46 0.86	1.34 0.25
225 <u> </u>	С	35.1	1.34	0.86	0.25
	Se	oter			

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Figure 1. (a) Schematic illustrations of the sliding friction treatment set-up, (b) a photograph of a Cu sheet after sliding friction treatment and (c) the geometry of the tensile specimen.



Figure 2. Cross-sectional optical images of (a) the original and SFT Cu samples under load of (b) 100 N and (c) 200 N, (d) a bright-field TEM image and a corresponding SAED insert showing the microstructure at the topmost surface in (c). Doubly pointed arrow indicates the sliding direction.



Figure 3. Cross-sectional optical images of (a) the original and SFT Ta samples under load of (b) 200 N and (c) 500 N. (d) A bright-field TEM image and (e) a dark-field TEM image showing the microstructure at the topmost surface layer in (c). Doubly pointed arrow indicates the sliding direction.



Figure 4. X-ray photoelectron spectra at different etching depths from the surface in the SFT

Cu and Ta samples.



Figure 5. (a) Tensile true stress-strain curves and dimensions of the tensile sample (inset), and (b) summaries of the data of the surface layer in SFT samples with different thickness as indicated, in comparison with the corresponding CG samples.